

UNIT-3

- ⇒ Transistor is a solid state device, whose operation depends upon the flow of electric charge carriers within within the solid.
- ⇒ The Transistor is capable of amplification and in most respect it is analogous to vacuum triode.
- ⇒ The main difference b/w the two is transistor is a current control device whereas vacuum triode is a voltage control device. Transistor advantageous than vacuum tubes.
- ⇒ Transistor has compact size, light weight, rugged construction, more resistive to shocks and vibrations, instantaneous operation (no heating required) low operating voltage, high operating efficiency (no heat loss) and long life if operated within permissible limits of temp & frequency.
- ⇒ However Transistor, in comparison to vacuum triode, have some drawbacks also such as Loud hum noise, restricted operating temp (up to 75°C) and operating frequency (up to a few mHz only).

3, 11, 11',
 G₂, 63, 64, 65, 68, 71, 72, 80, 88, 89, 93
 A₈', A₃, ~~A₉~~ B₀ B₁ B₂ ~~B₃~~ C₀
 96, A₅, ~~A₉~~

Transistor is a three terminal, two junction semiconductor device. There are two categories. Bipolar & Unipolar. In bipolar transistors electrical conduction is due to holes and electrons.

⇒ Transistor was invented by John Bardeen and W.H. Brattain in 1948.

⇒ Why the Name Transistor?

Under normal working operation of transistor, it has two junctions. One junction is F.W.B & another junction is R.B. F.W.B junction offers low resistance, whereas reverse biased junction offers high resistance path. So giving a weak signal from high resistance region and taking out put from the low resistance region, we get an amplified signal. Hence Transistor indicates transfer of signal from low resistance to high resistance.

Transfer + Resistor = Transistor.

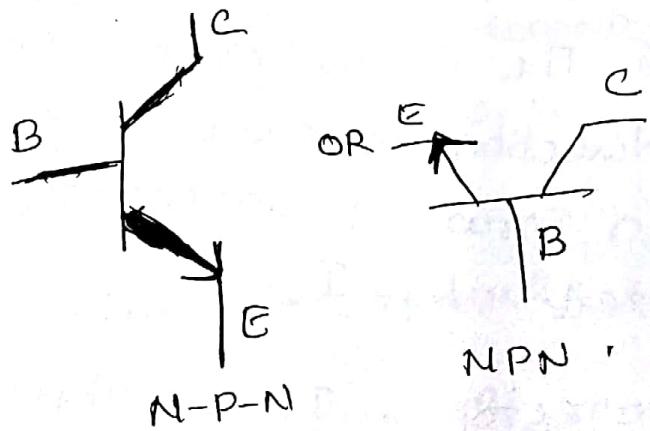
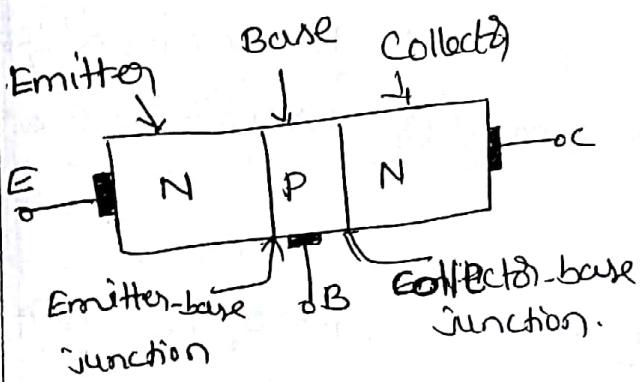
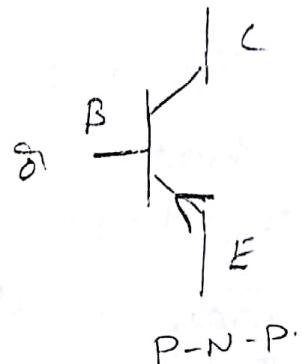
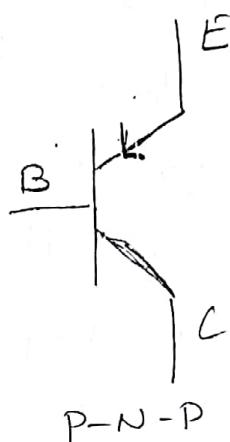
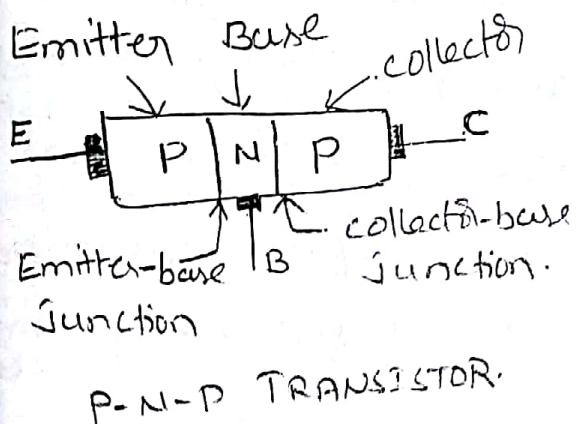
A Junction Transistor is simply a sandwich of one type of semiconductor material b/w two layers of the other type. Accordingly, there are two types of transistors NPN & PNP.

⇒ Transistors are made either from silicon or Germanium crystal.

than Germanium transistor because silicon has smaller cut-off current I_CBO , smaller variations due to variations in temperature, and higher operating temperature.

When a layer of P-Type material is sandwiched b/w two layers of N-Type material, The Transistor is known as N-P-N Transistor.

⇒ When a layer of N-Type material is sandwiched b/w two layers of P-Type material, The Transistor is known as P-N-P Transistor.



Each Type of Transistor has two p-n junctions. One junction b/w E & B, called emitter-base junction or simply the Emitter junction. and the other junction b/w B and C, called collector-base junction or simply collector junction.

The two junctions give rise to three regions provided with three terminals called the Emitter (E), Base (B) and collector (C)

Emitter :- It is left hand section (or region) of the Transistor and its main function is to supply the Majority charge carriers (Electrons in case of NPN Transistor) and holes in case of P-N-P Transistor to the base. The Emitter is always forward biased w.r.t base so that it is able to supply majority charge carriers to the base. The emitter is heavily doped so that it may be able to inject a large no of charge carriers in forward biased in order to maintain heavy doping without diluting it.

⇒ The arrow on the emitter lead specifies the direction of current flow when the E-B junction is in forward biased. The Emitter current represented by I_E .

Collector :- It is the right hand section of Transistor and its main function is to collect majority charge carriers. Collector is always reverse biased. So it is moderately doped, large in size to withstand the temperature generated at the collector. The Collector current is represented by I_C . No arrow indicated on collector so that it indicates its reverse leakage current. Collector current is always opposite to the direction of Emitter current.

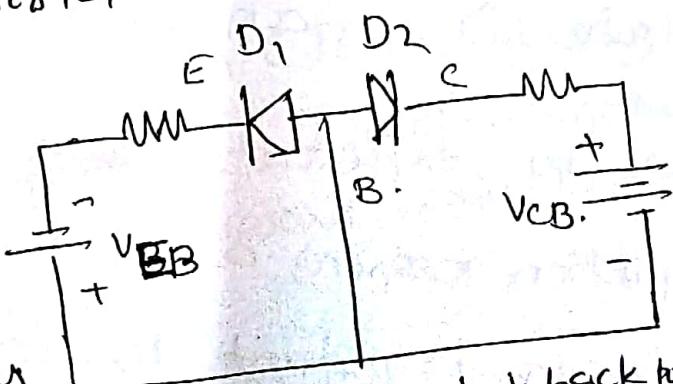
use! It is middle section of the Transistor and its main function is it pass the most ^{of the} injected charge carriers to the collector. It is very lightly doped to reduce the recombination within the base. So increase the I_C and it is very thin (order of 1μm) in comparison to either E and C.

⇒ It should be remembered that a Transistor is just like two diodes. The junction b/w E and B may be called as emitter base diode or Emitter diode. Similarly, The junction b/w base and collector may be called as collector base diode or simply collector diode.

⇒ Although, it is said that a Transistor is a device with two p-n diodes connected back to back, but it does not mean that two discrete diodes connected back to back as shown in fig, can work as a Transistor.

Why Two discrete diodes connected back to back can never work as a Transistor.

In such case, each diode has two equally doped regions (P & N) so that overall it has four equally doped regions. This would not work as base region is not the same as in Transistor.



Two diodes connected back to back

⇒ The key to the Transistor action is the light doped thin base b/w heavily doped emitter and moderately doped collector.

⇒ In N-P-N Transistor, the free \bar{e} passing through the base to the collector region have a short life time. As long as base is thin, the free \bar{e} can reach the collector. But in case of two discrete back to back connected diodes there are four doped regions instead of three and there is nothing that resembles a thin base region b/w E and C. Hence two discrete diodes connected back to back can never work as a Transistor.

TRANSISTOR ACTION:

Unbiased Transistor:

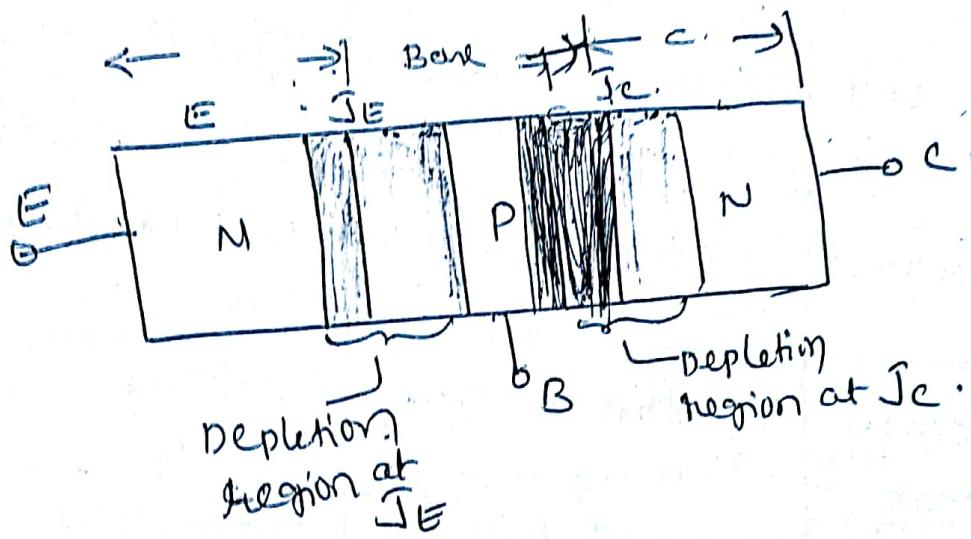
When no battery is connected b/w the terminals of Transistor is said to be Transistor is unbiased state or in an open circuit state.

⇒ Due to different doping levels of doping, the depletion regions at the two junctions are different. It is important to mention here that the depletion region penetrates more deeply in to lightly doped side.

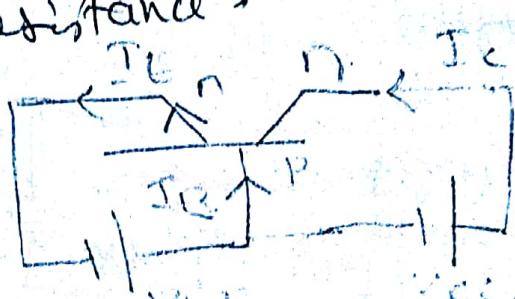
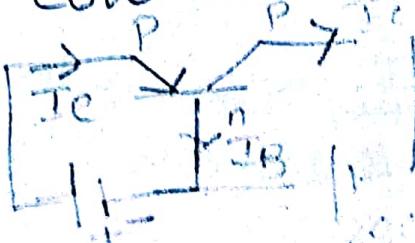
(u) 14.

The depletion region at E-J penetrates less in heavily doped emitter and extends more in base region.

⇒ Similarly The depletion region at collector junction penetrates less in ~~less~~ moderately doped collector and extends more in base region. (Collector is heavily doped than base). so the depletion region formed at collector junction is larger than depletion layer formed at Emitter junction.



To operate a transistor, it should be properly biased. The E-B Junction (J_E) is always F.W.B. biased. The E-B Junction (J_E) is always F.W.B. biased. The collector - Base junction (J_C) is always reverse biased. The Resistance of Emitter junction is very small (because it is in forward biased) compared to collector junction resistance.

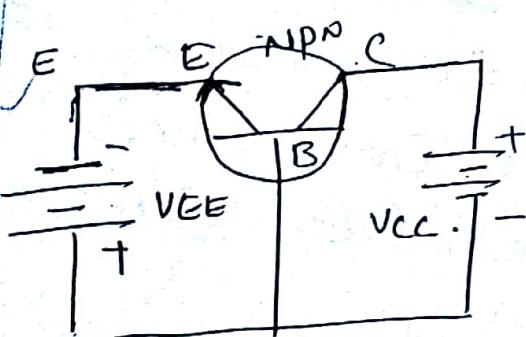


TRANSISTOR BIASING :

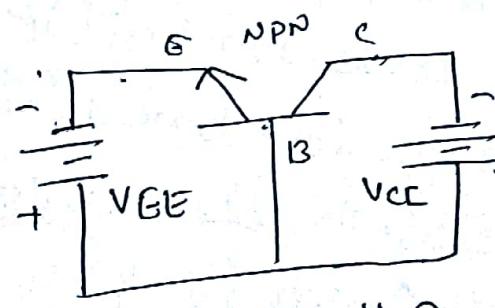
The process of applying DC voltage across different terminals of transistor is called Transistor biasing.

⇒ There are four possible ways of biasing a Transistor. These are called as modes of operation of Transistor.

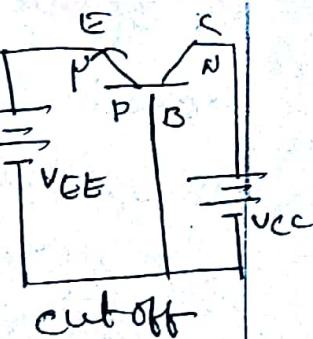
case	E-B Junction	C-B Junction	Region of operation
I	Forward biased	Reverse biased	Active
II	Forward biased	Forward biased	Saturation
III	Reverse biased	Reverse biased	Cut-off
IV	Reverse biased	Forward biased	Inverted.



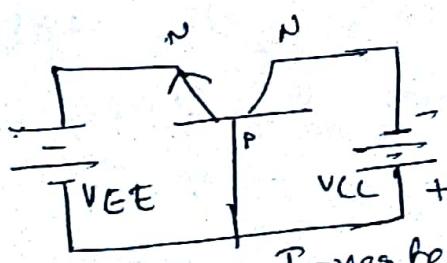
Active region.



Saturation.



Cut-off



Inverted region.

In this region action of Transistor is very poor

OPERATION OF P-N-P TRANSISTOR :

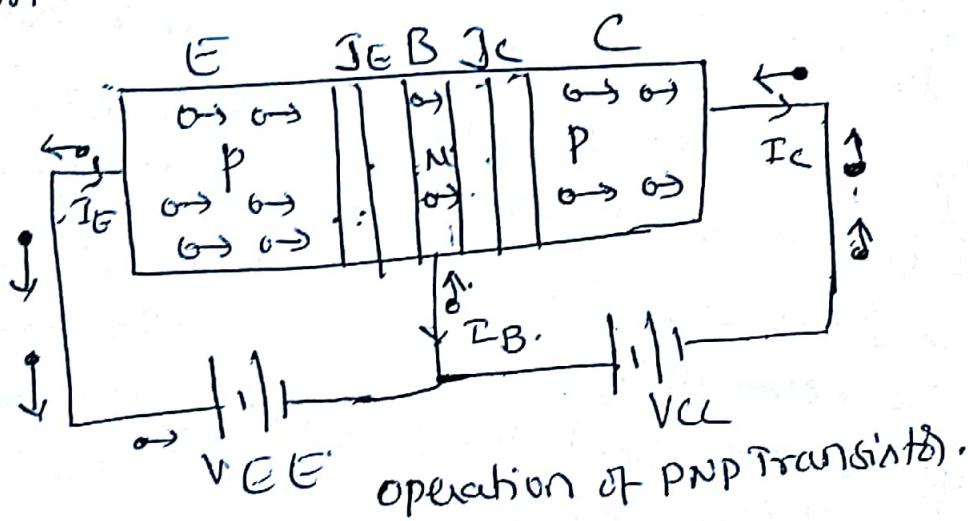
⇒ P-N-P Transistor with E-B junction as forward biased and C-B junction as reverse biased. The operation of P-N-P Transistor is as follows:

The holes in p-region (emitter) are repelled by +ve terminal of battery V_{EE} : so the holes are moving towards to the base. Due to forward biasing the potential barrier at emitter junction is reduced so depletion width is decreased; the holes are able to cross the junction & enter in to the base region. This constitute the emitter current I_E . The width of the base region is very thin and it is lightly doped hence only two to 5 percent of holes recombine with the free e^- of N region. This constitute the base current I_B , but it is very small. The remaining holes (95% to 98%) are able to drift across the base and enter the collector region. They are swept up by -ve collector voltage V_{CC} to form collector current I_C .

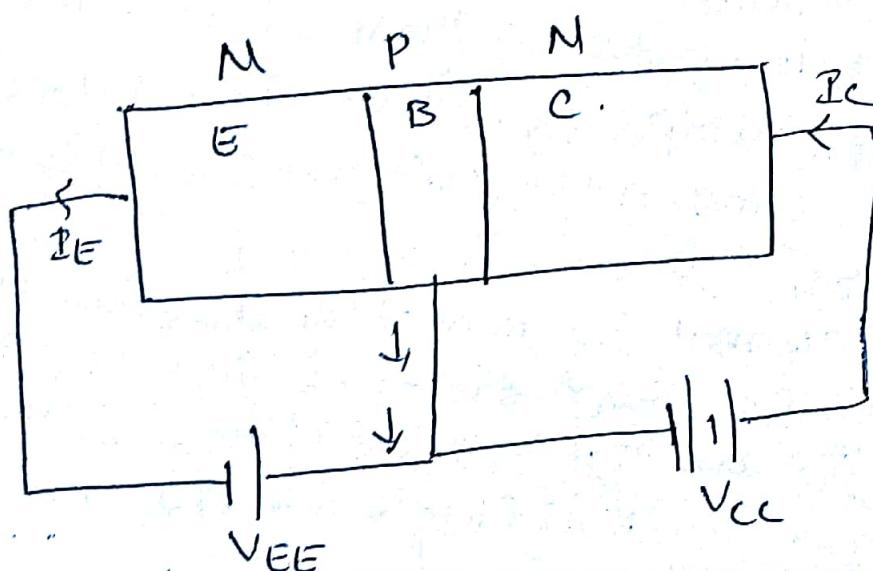
This constitutes the current conduction within the P-N-P Transistor ⇒ current conduction from E to C. i.e. takes place by hole conduction in a P-N-P Transistor.

Majority charge carriers in a P-N-P Transistor are holes. The conduction in the external circuit is carried out by electrons. The collector current I_C is slightly less than the Emitter current I_E . This is due to the fact that 2 to 5% of holes are lost in recombination with e^- in base region. So I_C is slightly less than I_E .

⇒ The collected current is a function of Emitter i.e. with increasing or decreasing in emitter current a corresponding change in collector current observed.
 ⇒ Beside hole current, there is an electron current which flows from base region to emitter region. This current depends upon emitter-base potential. As the width of the base region is very small, the ratio of hole current to electron current is very small. So for all practical purposes, the electron current may be neglected. thus only the hole current plays the important role in the operation of P-N-P Transistor.



operation of NPN Transistor.



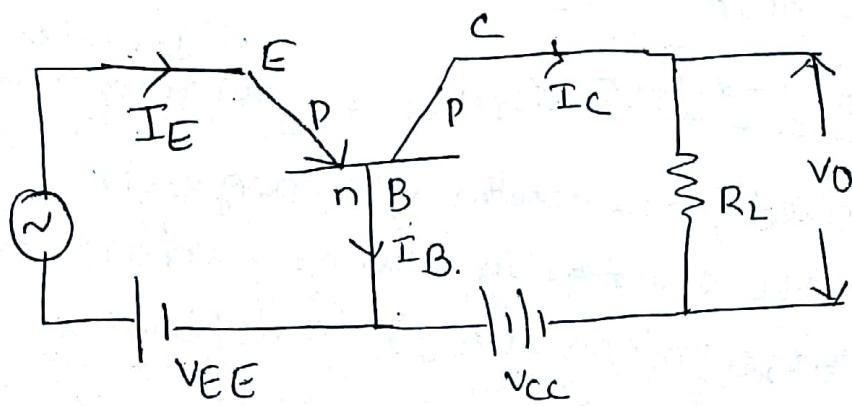
TRANSISTOR CONFIGURATIONS!

- 1:- Common-base (CB)
- 2:- Common-Emitter (CE).
- 3: Common-collector (CC)

Here the term "common" is used to denote the transistor lead (terminal) which is common to the IIP and oIP circuits. This is because, when a Transistor is connected in a circuit, four terminals are required (two terminals for IIP, two for oIP) while transistor has ^{only} three terminals. To overcome this difficulty we are using one terminal in common for both IIP & oIP.

Generally the common terminal is grounded. Each configuration has specific advantages & disadvantages.

1. Common - base Configuration.



⇒ In this Configuration, the IIP signal is applied b/w Emitter and base while the oIP is taken from collector and base. As base is common to IIP and oIP hence name is Common-base configuration.

current amplification factor (α): when no signal is applied, then the ratio of the collector current to the emitter current is called dc alpha (α_{dc}) of a Transistor.

$$\alpha_{dc} = -\frac{I_c}{I_E}$$

(-ve sign signifies that I_E flows in to transistor while I_c flows out of it).

if we write α_{dc} simply by α then

$$\alpha = -\frac{I_c}{I_E} \quad \text{--- (1)}$$

α measures the quality of a transistor. Higher is the value of α better is the transistor in the sense that collector current approaches the emitter current.

From eq(1)

consider only magnitudes of the currents

$$I_B = I_E - I_c$$

$$I_c = \alpha \cdot I_E$$

$$I_B = I_E - \alpha I_E$$

$$I_B = I_E [1 - \alpha] \quad \text{--- 2}$$

$$I_E = -[I_B + I_c]$$

-ve indicates outgoing current

When ~~no~~ signal is applied, the ratio of change in collector current to the change in emitter current at constant collector base voltage (V_{CB}) is defined as current amplification factor.

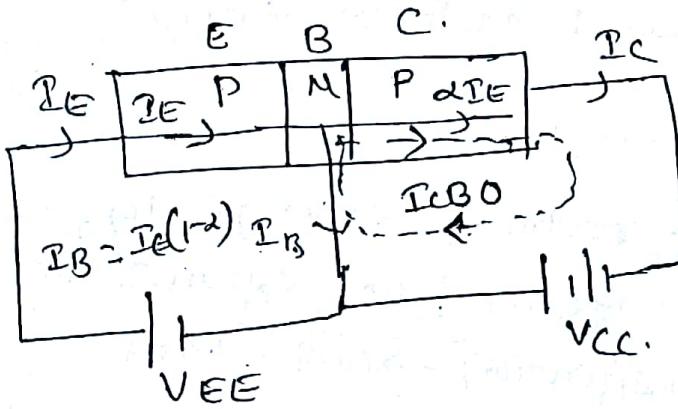
$$\alpha_{ac} = -\frac{\Delta I_c}{\Delta I_B}$$

For all practical purpose $\alpha_{dc} = \alpha_{ac} = \alpha$.

α range is 0.9 to 0.99.

Total collector current: - The total collector current consisting of two parts.

- i: Current produced due to majority charge carriers and its value is $I_C = \alpha I_E$
- ii The leakage current I_{CBO} . This current is due to the motion of minority carriers across B-C junction on account of it being reverse biased. This is much smaller than αI_E . The leakage current is abbreviated as I_{CBO} i.e. collector - base current with emitter open.



Total collector current

$$I_C = \alpha I_E + I_{CBO}$$

if $I_E = 0$ (emitter open)

$$I_C = I_{CBO}$$

I_C can also be expressed as

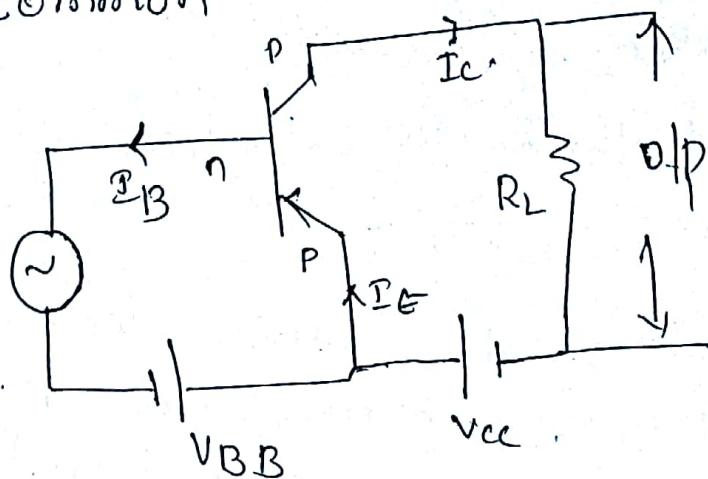
$$I_C = \alpha I_E + I_{CBO}$$

$$= \alpha [I_C + I_B] + I_{CBO}$$

$$I_C [1 - \alpha] = \alpha I_B + I_{CBO}$$

$$I_C = \frac{\alpha I_B}{1 - \alpha} + \frac{I_{CBO}}{1 - \alpha} \Rightarrow \frac{\alpha}{1 - \alpha} I_B + \frac{1}{1 - \alpha} I_{CBO}$$

2) Common-Emitter (CE) CONFIGURATION.



$$\text{Current gain} = \frac{\text{OIP}_{\text{current}}}{\text{OIP}_{\text{dissipation}}}$$

In this configuration OIP is applied b/w B & E.
 OIP is taken across collector & emitter. Emitter is common to OIP and OIP. clcts. hence it is called as CE configuration.
 Base Amplification factor B : When no signal is applied, B_{dc} is called dc Beta (β_{dc}).
 The ratio of I_C to I_B is called β_{dc} .

$$\beta_{dc} = B = \frac{I_C}{I_B} \quad \text{--- (1)}$$

When signal is applied, the ratio of change in collector current to the change in base current is defined as base current amplification factor. They

$$\beta_{ac} = B = \frac{\Delta I_C}{\Delta I_B} \quad \text{--- (2)}$$

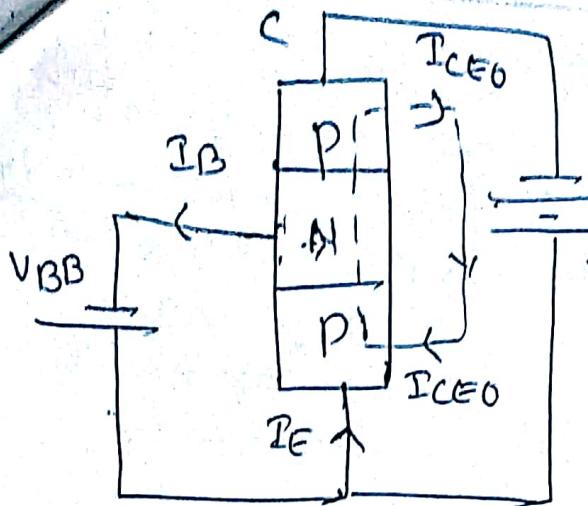
$$I_C = B I_B$$

Almost in all Transistors, I_B is less than 5% of I_E . Due to this fact, B is generally greater than 20. B range is 20 to 500. Hence this configuration is frequently used.

The Total collector current :

$$I_C = B I_B + I_{CEO}$$

I_{CEO} is the leakage current.



I_{CEO} is the leakage current

$$I_C = \beta I_B + I_{CEO} \quad \text{---(3)}$$

If I_B is zero

$$I_C = I_{CEO}.$$

We know

$$I_E = I_B + I_C.$$

$$\beta = \frac{\alpha}{1-\alpha}$$

$$I_C = \alpha I_E + I_{CBO}.$$

$$\beta = \frac{\alpha}{1-\alpha} + 1 - 1$$

$$I_C = \alpha (I_E + I_B) + I_{CBO}$$

$$1 + \beta = \frac{\alpha + 1 - \alpha}{1 - \alpha}$$

$$I_C [1 - \alpha] = \alpha I_B + I_{CBO}$$

$$1 + \beta = \frac{1}{1 - \alpha}$$

$$I_C = \frac{\alpha}{1 - \alpha} I_B + \frac{1}{1 - \alpha} I_{CBO}. \quad \text{---(4)}$$

Compare 3 & 4.

$$\beta = \frac{\alpha}{1 - \alpha}$$

$$I_{CEO} = \frac{1}{1 - \alpha} I_{CBO}.$$

Substitute I_{CEO} value in eqn (3)

$$I_C = \beta I_B + \frac{1}{1 - \alpha} I_{CBO} = \beta I_B + (\beta + 1) I_{CBO}$$

Relation b/w α and β .

$$\alpha = \frac{I_C}{I_E} \quad \beta = \frac{I_C}{I_B}$$

$$I_E = I_C + I_B.$$

$$I_B = I_E - I_C.$$

$$\beta = \frac{I_C}{I_E - I_C} = \frac{I_C / I_E}{1 - \frac{I_C}{I_E}} = \frac{\alpha}{1 - \alpha}.$$

$$\boxed{\beta = \frac{\alpha}{1 - \alpha}}$$

$$\beta(1 - \alpha) = \alpha$$

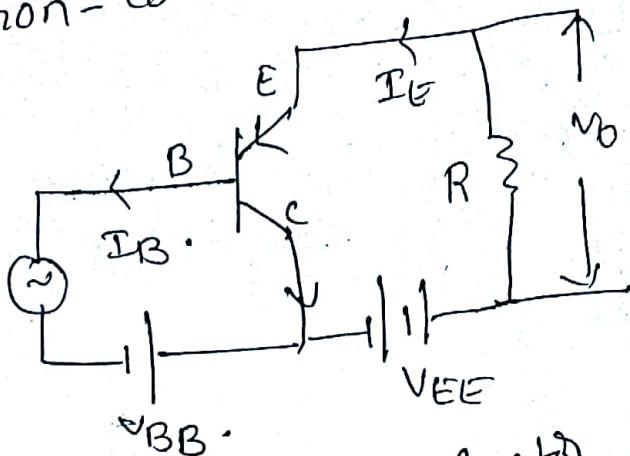
$$\beta - \beta\alpha = \alpha$$

$$\beta = \alpha(1 + \beta)$$

$$1 - \alpha = \frac{1}{1 + \beta}$$

$$\boxed{\alpha = \frac{\beta}{1 + \beta}}$$

common-collector configuration.



This configuration provides same current gain as C-E configuration.

$$\Delta I_E = \Delta I_C$$

But voltage gain is less than one.

current Amplification factor $\gamma = \frac{I_E}{I_B}$

When signal is applied. $\gamma = \frac{\Delta I_E}{\Delta I_B}$.

Total emitter current $I_E = I_C + I_B$.

$$I_C = \alpha I_E + I_{CBO}$$

$$I_E = I_B + \alpha I_E + I_{CBO}$$

$$I_E = I_B + \alpha I_E + I_{CBO}$$

$$I_E(1-\alpha) = I_B + I_{CBO}$$

$$I_E = \frac{1}{1-\alpha} I_B + \frac{1}{1-\alpha} I_{CBO}$$

$$\text{or } I_E = (1+\beta) I_B + (1+\beta) I_{CBO}$$

Application :- This configuration has very high O/P Resistance ($\approx 750 \text{ k}\Omega$) and very low O/P resistance ($\approx 25 \Omega$).

Relation b/w γ and α .

$$\gamma = \frac{I_E}{I_B} \quad \alpha = \frac{I_C}{I_E} \quad I_B = I_E - I_C$$

$$\gamma = \frac{I_E}{I_E - I_C} = \frac{1}{1 - \frac{I_C}{I_E}} = \frac{1}{1 - \frac{1}{1-\alpha}}$$

Relation b/w γ & β .

$$1-\alpha = \frac{1}{1+\beta}$$

$$\gamma = \frac{1}{1-\alpha} = 1+\beta$$

TRANSISTOR AS AN AMPLIFIER:

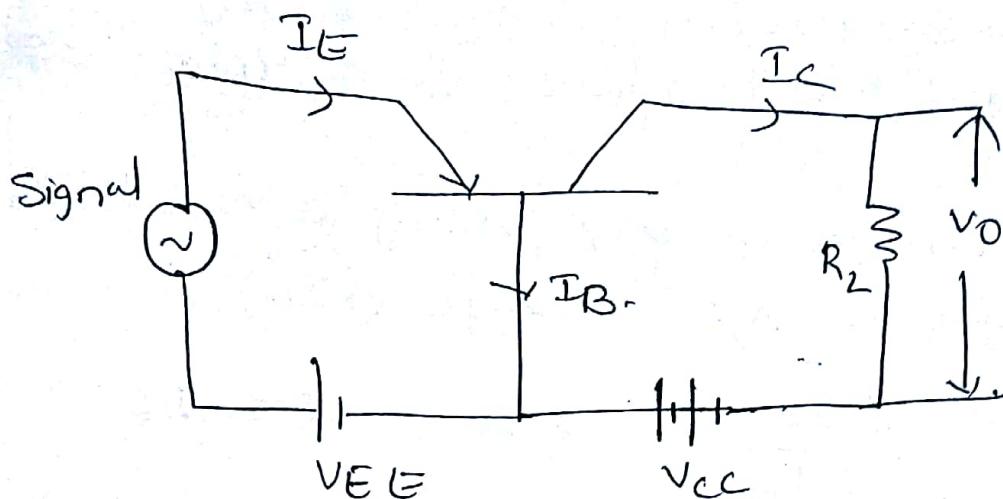


Fig: Transistor as an Amplifier.

→ The weak signal to be amplified is applied b/w emitter - base circuit and o/p is taken across collector - base circuit. The dc voltage V_{EE} is also connected in the o/p circuit. Now the question is that why V_{EE} is connected in the circuit?

→ Let, for the instant, V_{EE} is not connected in the circuit. Now for the -ve peak of the applied signal, the E-B junction will be reverse biased. This is not desirable because to achieve faithful amplification, the DIP clt should always remain forward biased. For this purpose, emitter ~~bias~~ bias battery V_{EE} of such magnitude that DIP clt is always forward biased regardless of the polarity of the signal is connected.

A. small change in signal voltage produces an appreciable change in emitter current because the DIP clt has low resistance. change in I_C causes same change in I_C .

When collector current I_C flows in R_L a load voltage is developed across it. So weak signal is applied in the O/P clkt appears & Amplified signal at O/P.

Let a small change in ΔV_i (ΔV_i), a relatively Large emitter current change ΔI_E .

$$\alpha = \frac{\Delta I_C}{\Delta I_E} \quad \Delta I_C = \alpha \Delta I_E$$

The change in O/P voltage is

$$\Delta V_O = \Delta I_C \times R_L \\ = R_L \alpha \Delta I_E$$

voltage gain $A = \frac{\Delta V_O}{\Delta V_i}$

$$\Delta V_i = \Delta I_E \times r_e$$

$$A = \frac{\alpha \Delta I_E R_L}{\Delta I_E r_e}$$

$$A = \frac{\alpha R_L}{r_e}$$

where r_e is internal emitter resistance
(Dynamic resistance of emitter junction).

$$R_L \gg r_e$$

Calculate the collector current and $I_E = \alpha I_B + I_{CBO}$
 a Transistor with $\alpha_{DC} = 0.99$ $I_{CBO} = 50 \mu A$
 $I_B = 20 \mu A$.

Ans $I_C = \alpha I_E + I_{CBO}$
 $= \alpha(I_C + I_B) + I_{CBO}$

$$I_C = 6980 \mu A$$

$$I_E = I_C + I_B$$

$$I_E = 7 \text{ mA}$$

2). Determine I_B I_C I_E and V_{CE} for
 CE ckt $V_{CC} = 15V$ $V_{BB} = 5V$ $R_B = 300k\Omega$.

$$R_C = 1k\Omega \quad V_{BE} = 0.7V \quad \beta = 100$$

Apply KVL.

$$I_B R_B + V_{BE} = V_{BB}$$

$$I_B = \frac{V_{BB} - V_{BE}}{R_B}$$

$$I_B = 14.3 \mu A$$

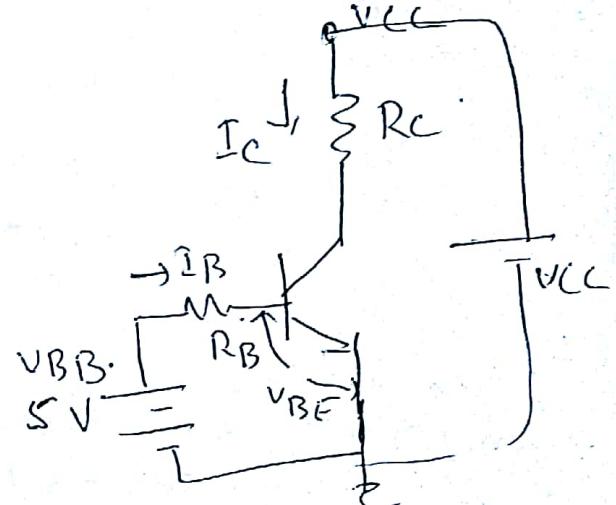
$$I_C = \beta I_B = 1.43 \text{ mA}$$

$$I_E = I_C + I_B = 1.45 \text{ mA}$$

Applying KVL at OLP

$$V_{CE} = V_{CC} - I_C R_C$$

$$= 13.57V$$



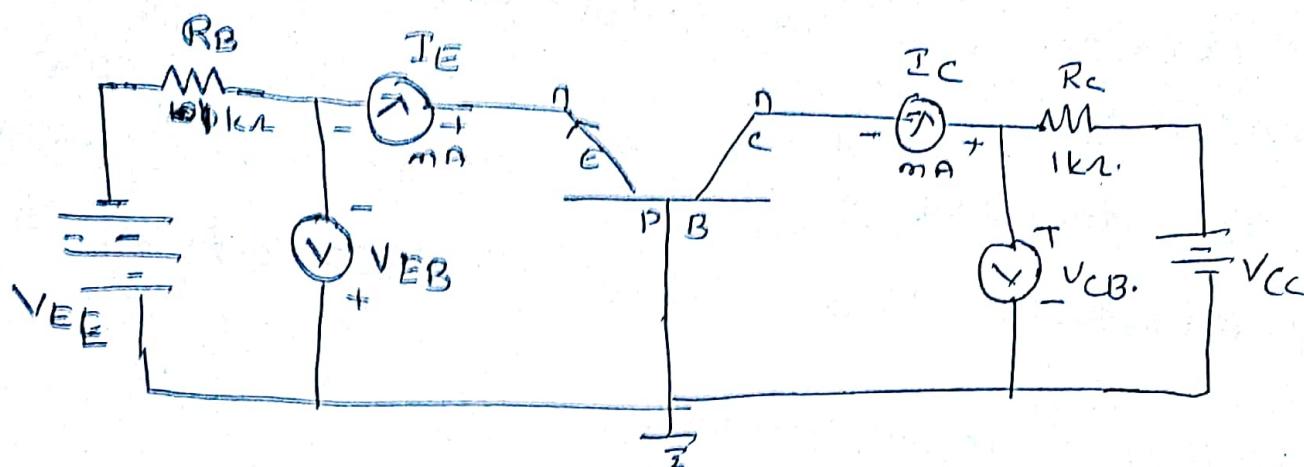
Typical n-p-n Transistor Junction Voltages at 25°C

	$V_{CE(sat)}$	$V_{BE(sat)}$	V_{BE} Active	V_{BE} Cut-in	V_{BE} Cut-off
Si	0.3 V	0.7 V	0.6 V	0.5 V	0.6
Ge	0.1 V	0.3 V	0.2 V	0.1 V	-0.1

Comparison of CB, CE, CC Configuration.

Property	CB	CE	CC
1) O/P Resistance	Low (about 100Ω) about 100Ω (22.5Ω)	Moderate about $1.5\text{ k}\Omega$ ($1\text{ k}\Omega$)	Very High about $10^5 \text{ k}\Omega$ $14(4\text{ k}\Omega)$
2) O/I P Resistance	Very high About $400\text{ M}\Omega$ ($1.72\text{ M}\Omega$) (about $400\text{k}\Omega$)	Medium $4.5\text{ k}\Omega$ about $50\text{k}\Omega$	Low $80.15\text{ k}\Omega$ about $50\text{k}\Omega$
3) A _I	Low (0.98) Less than unity	High ≈ 46.5	High 47.5
4) A _V	Medium. High (≈ 50) about 150	High about 500	Low 0.99
5) Phase shift.	$0 \text{ or } 360^\circ$	180°	$0 \text{ or } 360^\circ$
6) Applications	For high freq. clkt	Audio freq. Amps	For Impedance matching

CHARACTERISTICS OF Common Base CIRCUIT.

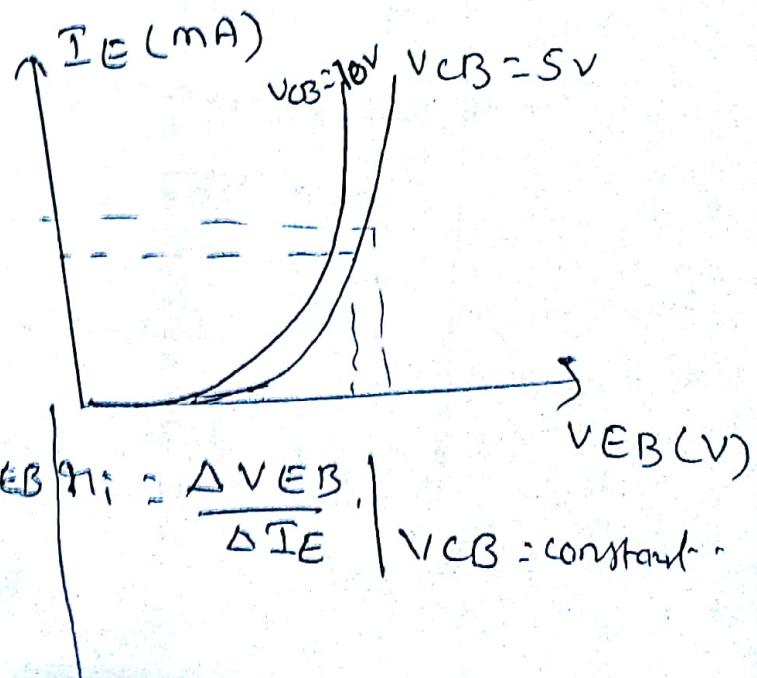


- ⇒ Supply Voltage V_{EE} makes E-B is in F.W.B
- 2 V_{CC} makes C-B Junction in Reverse bias.

INPUT CHARACTERISTICS:

⇒ It is the curve between an Input voltage V_{EB} and Input current I_E at constant V_{CB} . I_E is taken along Y-axis & V_{EB} is taken along X-axis.

⇒ when V_{EE} is increased
After cut in voltage
(barrier potential) (0.7V Si
0.3V for Ge), The Emitter
current $I_E \uparrow$ rapidly
with small increase in V_{EB} .

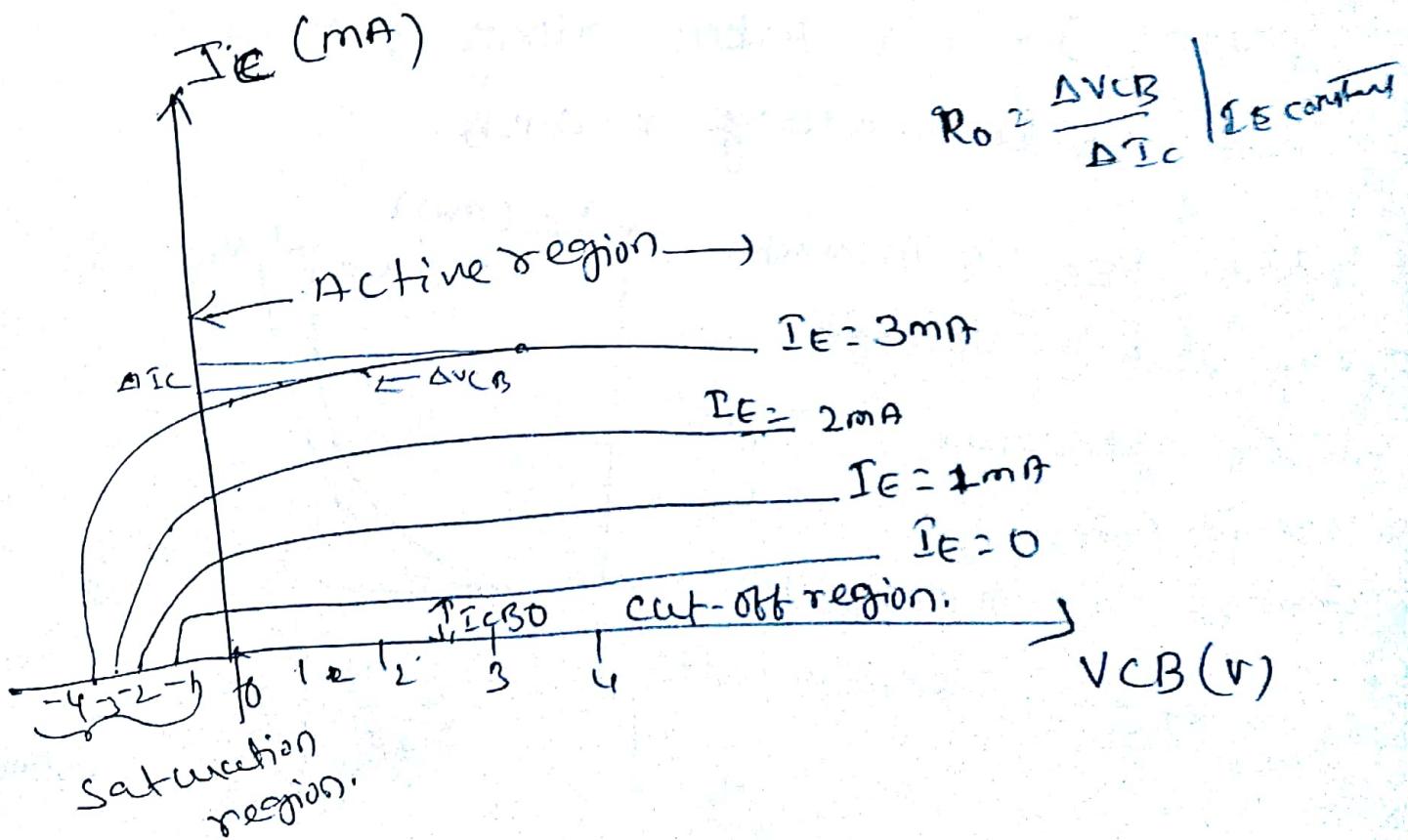


\Rightarrow It can be observed that there is a decrease in base width under Reversible condition.

\Rightarrow V_{CB} is +ve for n-p-n, -ve for p-n-p transistor.
On other hand V_{EB} is -ve for n-p-n, +ve for p-n-p

OUTPUT CHARACTERISTICS:-

- \Rightarrow The curve b/w collector current I_C and collector-base voltage V_{CB} at constant emitter current I_E represents the O/P characteristics.
- \Rightarrow Output characteristics has three basic regions. Active, cut-off, and saturation.

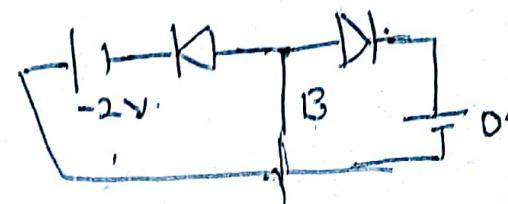


In cut-off region, (both J_E & J_C are reverse biased), a small amount of collector current $I_C = 0$, flows even when emitter current $I_E \neq 0$. This is collector leakage current I_{CBO} . Due to nothing (i.e. $V_{EE} = 0$, $I_E = 0$, $V_{EB} = 0$).

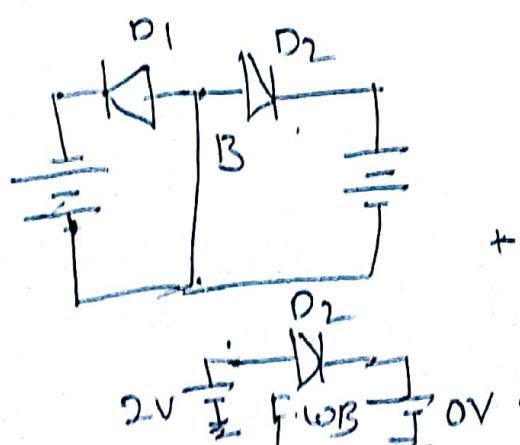
ii In the saturation region (Both J_E & J_C are forward bias). The collector current I_C flows even when $V_{CB} = 0$. Actually, in n-p-n transistor, V_{CB} is slightly negative in this region and because of this forward biasing. This results large change in I_C with small change in collector voltage.

$$V_{EE} = 0V, I_E = 2mA$$

V_{CC} is \uparrow from $0V$
 $V_{CC} = 0V$ now C-B is F.W.B.



$V_{CC} = 1V$. $I_C - I_B$ is in F.W.B
 $V_{CC} > 2V$ onwards I_C is in Reverse bias.



$$+2V \xrightarrow{V_A > V_C} \begin{array}{c} V_A \\ | \\ V_C \\ | \\ D_2 \\ | \\ 0V \end{array}$$

\Rightarrow To keep I_E value is constant (e.g.: 2mA) we have to increase V_{EE} value upto some extent. For example $V_{EE} = 2V$ to get $I_E = 2mA$. When $V_{EE} < V_{CC}$, now vary the V_{CC} from 0V onwards up to 2V the I_C is in forward bias because of $V_{EE} - 1 - D \frac{I_C}{V_{EE}}$. Whenever $V_{EE} < V_{CC}$ onwards I_{C-B} is $V_{EE} > V_{CC}$ in reverse biased.

Active region: In this region I_{E-B} is in F-BWB. I_{C-B} is in Reverse bias, The collector current is essentially independent of collector voltage and depends only upon Emitter current. In this region I_C is almost constant. So transistor can be said to work as constant-current source. This provides very high dynamic o/p resistance.

$$R_o = \frac{\Delta V_{CB}}{\Delta I_C} \mid I_E \text{ constant}$$